



1752

PATENT
30205/37777

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Jae Chang Jung et al.

Serial No.: 10/054,095

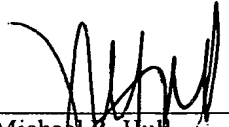
Filed: January 22, 2002

For: Chemical Amplification
Photoresist Monomers, Polymers
Therefrom and Photoresist
Compositions Containing the Same

Group Art Unit: 1752

Examiner: Rosemary E. Ashton

) I hereby certify that this paper and the
) documents referred to as enclosed
) therewith are being deposited with the
) United States Postal Service as first class
) mail, postage prepaid, on **November 21,**
) **2003**, in an envelope addressed to
) Commissioner for Patents, P.O. Box
) 1450, Alexandria, Virginia 22313-1450

)
) 
) Michael K. Huh
) Reg. No. 35,902
) Attorney for Applicants

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

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TC 1700

Dear Sir:

In response to the office action mailed on August 21, 2003, please amend the above-identified patent application as follows: